## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of: DiCarlo *et al.*Application No.: 11/750,142

Filed: 12/31/2003

Docket: TI-36187

Examiner: Vinh, Lan

Art Unit: 1765

For: Method for Removal of Pattern Resist Conf. No.: 7928

Over Patterned Metal Having an

Underlying Spacer Layer

## COMMENTS ON STATEMENT OF REASONS FOR ALLOWANCE

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I hereby certify that the above correspondence	is being filed electronically with
the U.S. Patent and Trademark Office on the o	date indicated below.
/Sue Short/	12/21/07
Sue Short	Date

Dear Sir:

In response to the Notice of Allowance and Fee(s) Due mailed October 4, 2007, Applicants submit the following comments:

## REMARKS

The Applicants agree with the Examiner's conclusions of patentability, without necessarily agreeing with or acquiescing in the Examiner's reasoning or comments. The Applicants submit that the claims of the above-identified application are allowable because the prior art fails to anticipate or render obvious the invention as claimed.

Respectfully submitted,

/Charles A. Brill/ Charles A. Brill Reg. No. 37,786

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